



# Field emission of vertically aligned $V_2O_5$ nanowires on an ITO surface prepared with gaseous transport

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## ABSTRACT

Growing  $V_2O_5$  nanowires (NWs) on a conducting glass substrate combines gaseous transport and pyrolytic deposition of vanadium polyoxometalate anions, and yields vertically aligned vanadium-oxide nanowires. Scanning electron and transmission electron microscopy, selected-area electron diffraction, Raman spectra and powder X-ray analyses indicate that  $V_2O_5$  nanowires as synthesized were single-crystalline and grew anisotropically along direction [010].  $NH_2OH \cdot HCl$  served not only as a reducing agent to produce vanadium polyoxometalate clusters but also as a source of  $NH_3$  gas to facilitate the vapor pyrolysis and deposition. The optical properties of  $V_2O_5$  nanowires exhibit a character dependent on structure. Field emission (FE) measurements show a small turn-on field voltage  $\sim 8.3$  V/ $\mu m$ , maximum current density 1.8 mA/ $cm^2$ , and a linear Fowler–Nordheim behavior.

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## 1. Introduction

Metal-oxide nanocrystals with a one-dimensional (1D) structure, such as a nanowire (NW) [1,2], nanotube [3], nanorod [4,5] or nanoribbon [6–8], show unique physical and chemical properties because of their large surface area and unique shape, which have made these materials effective for applications in photovoltaic devices [2,9,10], field emission (FE) display [3,11], etc. Among these materials,  $V_2O_5$  exhibits a peculiar structural type and a band gap  $\sim 2.5$  eV; its prospective applications include photochromic and electrochromic devices [2,10], chemical sensing [12,13], catalysis [14], and positive electrodes of rechargeable lithium battery [15,16]. The structure of orthorhombic  $V_2O_5$  exhibits layers of a 2D network containing chains of edge-sharing  $VO_5$  square pyramids with five-fold coordination of vanadium and oxygen atoms. Among syntheses of  $V_2O_5$  with a 1D nanostructure are template-assisted growth [4], surfactant/inorganic self-assembly [17], e-beam sputtering, chemical-vapor deposition [18], pulsed laser deposition [19,20] and hydrothermal [1,3,5,17] approaches. Vertically aligned  $V_2O_5$  nanorods are grown through template-based electrodeposition on an aluminum substrate or sol electrophoretic deposition on an ITO substrate [4], but these methods generally require polymers as template materials [1,3,11,21], the products are polycrystalline, and the conditions of electrodeposition are difficult to control.

We applied an original route of vapor pyrolysis and deposition to grow an aligned 1D nanostructure of  $\alpha$ - $MoO_3$  of controlled size on a glass substrate with a water-soluble polyoxometalate compound,  $(NH_4)_{12}[Mo_{36}O_{108}(NO)_4 \cdot (H_2O)_{16}] \cdot 33H_2O$  ( $Mo_{36}$ ) [22]. In the use of this technique, a precursor that promotes the initial deposition of seed crystals on a substrate is a critical factor for the formation of aligned  $\alpha$ - $MoO_3$  nanorods. This preparation is expected to be useful for the growth of a new metal oxide with a desired nanostructure from a suitable precursor. Here we report the deposition of vertically aligned  $V_2O_5$  nanowires under mild conditions without template materials. The results of field emission measurements show small actuation voltages and a large current density of  $V_2O_5$  nanowire arrays, which properties are prospectively useful in an optoelectronic nanodevice.

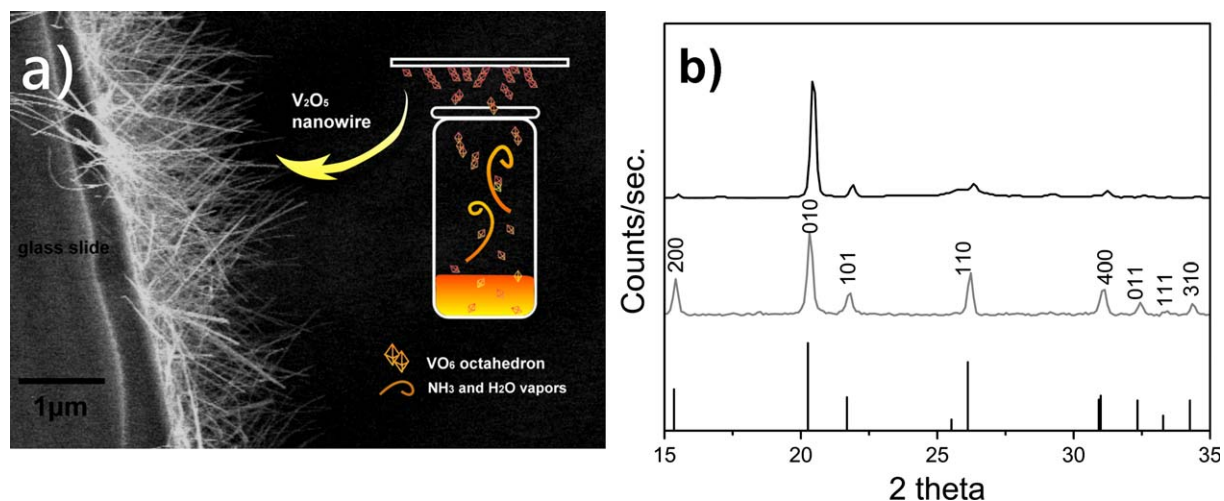
## 2. Experiments

### 2.1. Synthesis

$V_2O_5$  NWs were grown on a substrate with a method simple, economical and free of template. A mixture of  $V_2O_5$  powder (0.4 g, Aldrich, 99.99%),  $NH_2OH \cdot HCl$  (0.4 g, Fluka, 99.99%), and  $NH_4Cl$  (0.4 g, Aldrich, 99.99%) was placed in a conical flask, and stirred at 23 °C. The mixture turned from orange to green, indicating the reduction of  $V_2O_5$  [21]. This solution (1 mL) was loaded into a glass vial (volume 15 mL, external diameter 10 mm, height 50 mm), and an ITO substrate was placed on top of the vial. Before each experiment, the ITO substrate was cleaned with an organic solvent and then rinsed in deionized water. The  $V_2O_5$  NW

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**Fig. 1.** (a) Schematic illustration of experiments to deposit  $V_2O_5$  NWs on the surface of a substrate. (b) XRD profile of  $V_2O_5$  NWs (black) as synthesized and residual  $V_2O_5$  powder from the bottom of the reaction vessel (gray).

were grown in a horizontal box furnace; a schematic illustration appears in Fig. 1a. The temperature was raised to 320–420 °C over varied durations (0.5–2 h); the substrate in the furnace cooled naturally to 23 °C. Additional experiments show that other substrates such as a glass slide and titanium metal foil can likewise serve to deposit  $V_2O_5$  NWs with procedures similar to those specified above. When the reaction proceeded without  $NH_2OH \cdot HCl$ , the  $V_2O_5$  as synthesized exhibited irregular shapes. These  $V_2O_5$  NWs as prepared are stable in air for several months. Under 450 °C treatment, no obvious difference occurs in XRD, scanning electron microscope (SEM) and the field emission test of  $V_2O_5$  NWs on ITO.

## 2.2. Characterization with XRD, UV, PL, SEM, TEM and FE

The product as prepared was characterized with powder X-ray diffraction (XRD, Bruker AXS D8 Advance, Leipzig Germany,  $CuK\alpha$  radiation at 40 kV and 40 mA), a scanning electron microscope (Hitachi, S-4700I, operated at 15 kV), a transmission electron microscope (TEM, JEOL, JEM-3000F, operated at 200 kV), ultraviolet and visible absorption spectra (Hitachi U-3010 spectrometer, scanning 190–1000 nm,  $Al_2O_3$  plate as reference), photoluminescence (PL, Jobin-Yvon Spex Fluorolog-3 fluorimeter,  $\lambda_{ex} = 365$  nm, filter wavelength = 400 nm, Xe lamp, 23 °C, scanning wavelength 200–800 nm), and Raman spectra (semiconductor laser,  $\lambda = 450$  nm; data were collected at 60 nm/min). Refining the maxima of the XRD patterns with least-squares fitting using the CELREF program yielded the unit-cell parameters [23]. For TEM experiments, the sample was prepared by first scraping the  $V_2O_5$  NWs from ITO glass, followed by ultrasonically dispersing the NWs in methanol for 5 min. The resulting methanol-NWs mixture was then dispersed onto a holey carbon-coated 100 mesh copper grid. The methanol evaporated in the dry environment, leaving a distribution of NWs on the carbon film. The field emission was measured in a vacuum chamber with a pressure less than  $3 \times 10^{-7}$  Pa near 23 °C. The distance between the sample and electrode was adjusted to 150, 120 and 60  $\mu m$ . The measurements were performed several times to obtain reproducible results.

## 3. Results and discussion

Fig. 1b show XRD patterns of a product as deposited on an ITO substrate and residue in the bottom of the reaction vial. Both

patterns showed several reflections that were indexed to the orthorhombic  $V_2O_5$  structure ( $a = 11.513(2)$  Å,  $b = 3.567(4)$  Å,  $c = 4.466(5)$  Å,  $V = 180.71(2)$  Å<sup>3</sup>,  $Pmmn$  (No. 59)—orthorhombic, JCPDF 41-1426); no signals due to impurity phases were detected. For the product on the ITO surface, a diffraction feature at  $2\theta \sim 20^\circ$  assigned as (010) is dominant among all other signals in the pattern. The diffraction signals from the residue in the bottom of vial showed no distinct preferential orientation.

The morphology of the  $V_2O_5$  NW as synthesized was examined with scanning and transmission electron microscopes, as shown in Fig. 2a. The side-view image clearly reveals  $V_2O_5$  NWs that are nearly vertical aligned to the surface of the ITO substrate with no irregular particle. The highly magnified SEM image evidently shows a single nanowire containing a smooth and clean surface throughout its length (inset of Fig. 2a). The  $V_2O_5$  wires as synthesized show ribbon-like morphology with an average width within 50–100 nm and a length up to several tens of micrometers.

The HR-TEM image taken of a portion of a nanowire revealed parallel lattice fringes with inter-layer distances  $\sim 1.109$  nm (Fig. 2b), which corresponds to planes (100) of  $V_2O_5$  in its orthorhombic phase. The SAED pattern (inset in Fig. 2b) reveals clear diffraction spots and the  $d$ -spacing parallel to the NW is close to 3.4 Å, indicative of the single-crystalline nature and confirming that the grown NWs are single-crystalline and grown preferentially along direction [010].

The results of investigating the effect of temperature on the growth of  $V_2O_5$  NWs on an ITO surface are shown in Fig. 3. The results show that products from experiments at both temperatures exhibit a wire shape of  $V_2O_5$ . The average length of  $V_2O_5$  wire deposited at 320 °C is about 10  $\mu m$ , which increases to  $\sim 100$   $\mu m$  when the experiment was performed at 420 °C, but the widths of each nanowire are similar ( $\sim 80$  nm). The side-view SEM images (inset of Fig. 3a and b) indicate that the density of coverage of  $V_2O_5$  NW is increased for the experiment at a higher temperature.

To understand how the  $V_2O_5$  NWs were formed, we tested several conditions of thermal evaporation to discern the effect of precursor on the deposition of  $V_2O_5$  nanomaterials on ITO glass. Without  $NH_2OH \cdot HCl$  there was no growth of  $V_2O_5$  on ITO glass at any temperature. Replacing  $NH_2OH \cdot HCl$  with  $NH_3$  (aq) or  $NH_4Cl$  in the precursor solution also yielded no sign of crystal growth on ITO glass. The presence of  $NH_2OH \cdot HCl$  in the growth process was found to be essential, which is not only provide the  $H_2O$  and  $NH_3$  vapor source, but also reduced  $V_2O_5$  to polyvanadate species

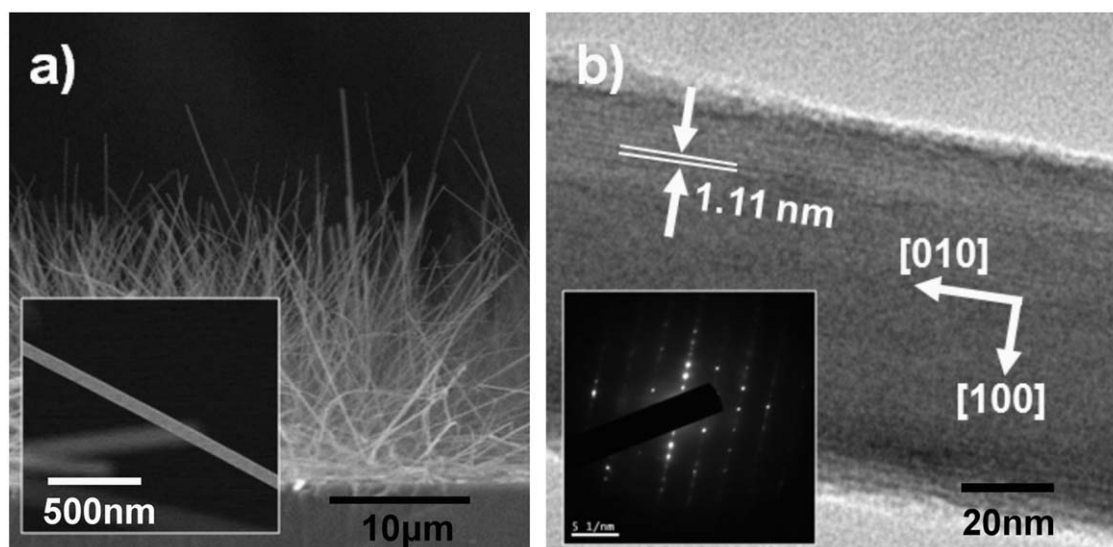


Fig. 2. SEM (a) and TEM (b) images of  $V_2O_5$  NWs as synthesized.

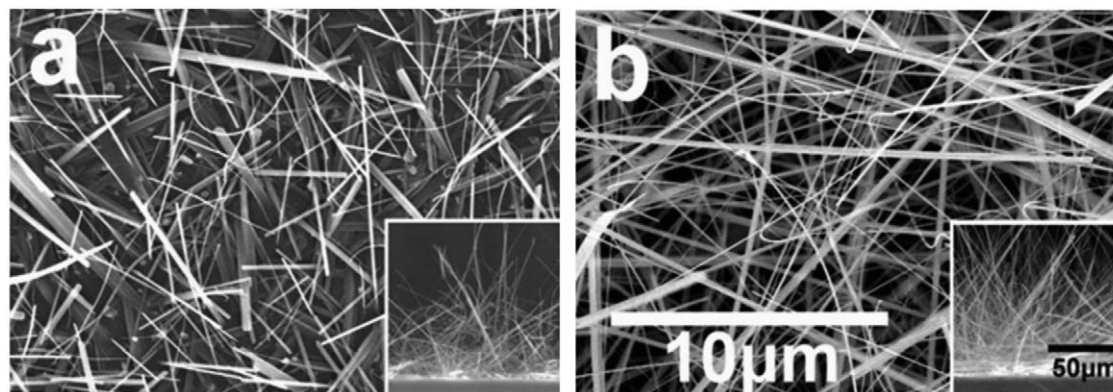


Fig. 3. SEM images of  $V_2O_5$  NWs as synthesized, deposited at 320 °C (a) and 420 °C (b).

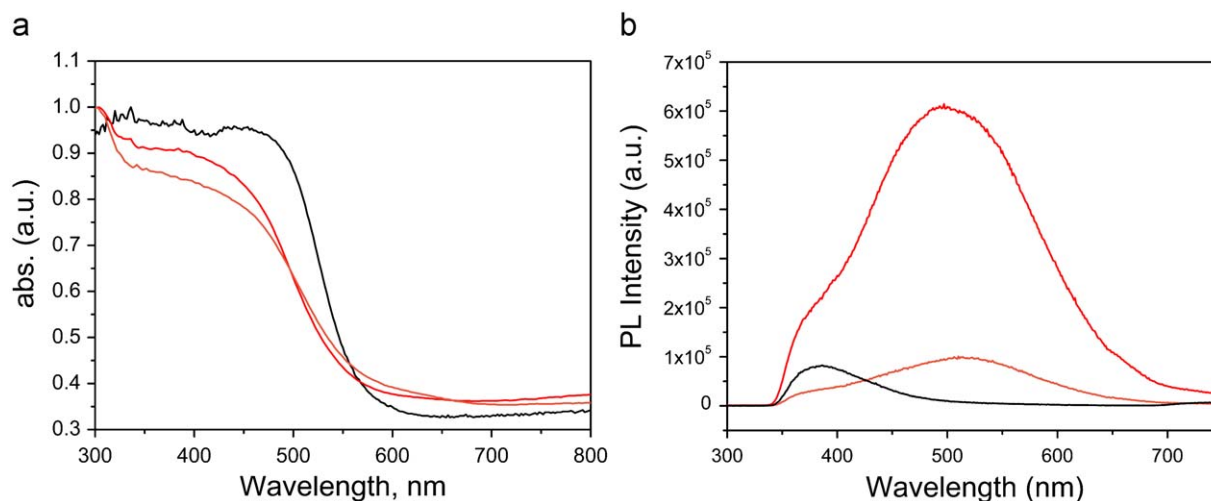
dissolved in solution. These results indicate that  $V_2O_5$  NWs were not deposited directly by bulk  $V_2O_5$  powder via gaseous transport. We demonstrated the mechanism to grow  $V_2O_5$  NW on substrate as follows. Initially, bulk  $V_2O_5$  powder dispersed in acid solution and was reduced by  $NH_2OH \cdot HCl$  to form green solution, indicative of the formation of polyvanadate species [24]. During the process to form  $V_2O_5$  NWs, polyvanadate species were delivered with the assistance of  $H_2O(g)$  and  $NH_3(g)$  (from  $NH_2OH \cdot HCl$ ) to deposit on the surface of the ITO glass substrate through interactions between polyvanadate and  $-OH$  and  $-O$  groups of glass substrate. Upon calcination at elevated temperatures, polyvanadate species tended to crystallize, leading to the formation of nanowires. It is possible that polyvanadate species were decomposed to form clusters made up of  $[VO_6]_n$  octahedra units, and then transferring to the glass surface to form  $V_2O_5$  NWs. Accordingly,  $NH_3$  and  $H_2O$  vapor produced on heating the solution become the carriers to assist nanocrystals of  $VO_x$  clusters to deposit on a glass substrate. The crystal growth is influenced by stacking of  $[VO_6]_n$  along the anisotropic direction [010].

We measured the optical absorption and photoluminescence to elucidate the intrinsic optical properties of the  $V_2O_5$  NWs aligned on an ITO surface. The UV–visible absorption spectrum of the films as deposited exhibits an onset of absorption near  $\sim 500$  nm, indicative of a band gap near 2.48 eV (Fig. 4a), which is blue-shifted relative to bulk  $V_2O_5$  powder ( $E \sim 2.2$  eV). The band gap shift is a result of defects and oxygen vacancies at the surface

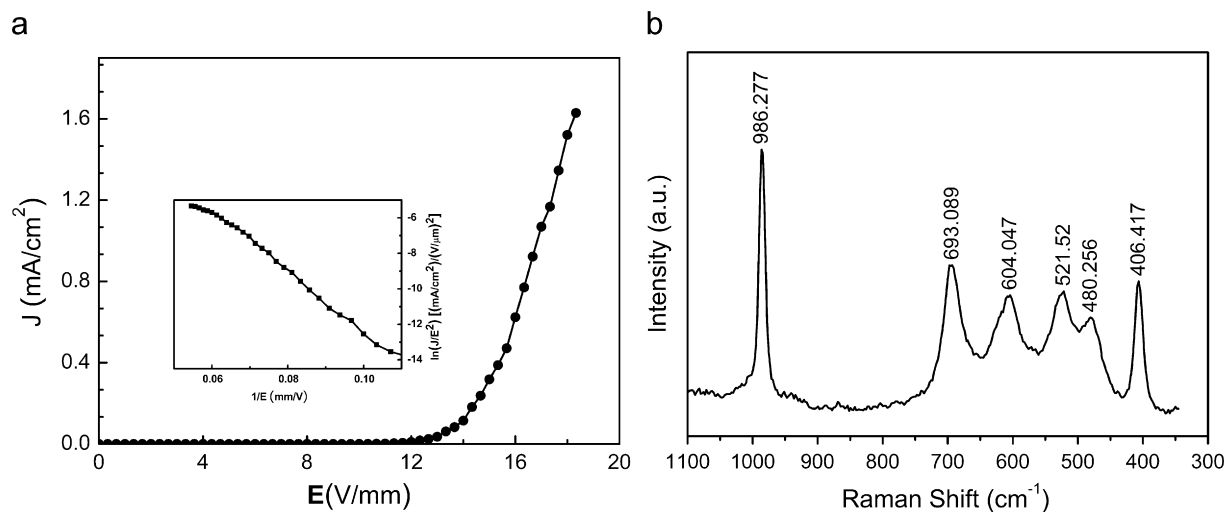
of  $V_2O_5$  NWs, which is typically observed for  $V_2O_5$  and transition metal oxide.

The luminescence properties of  $V_2O_5$  in both bulk powder and NWs were investigated with PL spectra with the same determinate area ( $0.5 \times 1$  cm<sup>2</sup>) and thickness (0.05 mm) for both bulk and NWs samples; the results appear in Fig. 4b. PL spectra of bulk  $V_2O_5$  powder show a main emission band with maximum near 375 nm, whereas spectra of  $V_2O_5$  NWs show the main band at  $\sim 500$  nm as well as a band centered about 375 nm. In previous discussion of the optical properties of  $V_2O_5$  in relation to the band structure, the emission of bulk  $V_2O_5$  is assigned to transitions of electrons between valence ( $O-2p$ ) and conduction band ( $V-3d$ ). The photoluminescence of  $V_2O_5$  NWs exhibits not only radiative transitions ( $\sim 375$  nm) similar to bulk  $V_2O_5$  but also transitions between the separate band from  $V-3d$  and the  $O-2p$  band [18,25,26].

The similar emission near 375 nm for bulk and  $V_2O_5$  NWs might be due to a removal of oxygen from the oxide lattices or reduced valence states of vanadium ions [10,20]. However, the significant difference of emission in the low energy band ( $\sim 500$  nm) is due to defects and oxygen vacancies at the surface of  $V_2O_5$  NWs. Broad photoluminescence lines were reported by Díaz-Guerra's group for  $V_2O_5$  with elongated nanostructures [18]. The emission of a  $V_2O_5$  nanowire deposited at 420 °C is greater than at 320 °C because of the greater density of coverage and the greater length of wires.



**Fig. 4.** (a) Diffuse reflectance spectrum of bulk  $V_2O_5$  powder (black) and  $V_2O_5$  NWs as synthesized, prepared at 320 °C (orange) and 420 °C (red). (b) PL spectrum for bulk  $V_2O_5$  powder (black) and  $V_2O_5$  NWs as synthesized, prepared at 320 °C (orange) and 420 °C (red). The black, orange and red lines are  $V_2O_5$  samples as bulk, wire at 320 °C and wire at 420 °C, respectively.



**Fig. 5.** (a) Emission current densities versus electric field for a sample as synthesized with an emitting surface of area 25 mm<sup>2</sup>. (b) Raman spectrum of  $V_2O_5$  NWs on Ti foil (red) and ITO (black) substrate.

The as-synthesized  $V_2O_5$  NWs with vertically aligned structure may exhibit interesting field emission effect, which was measured with a parallel-plate configuration of electrodes near 295 K with a separation 100  $\mu\text{m}$  between the anode and an emitting surface of area 25 mm<sup>2</sup>. Fig. 5a shows the emission current density ( $J$ ) from the  $V_2O_5$  NW as a function of applied field ( $E$ ). The turn-on field ( $E_{\text{to}}$ ) is  $\sim 8.3$  V/ $\mu\text{m}$  at a current density 10  $\mu\text{A}/\text{cm}^2$ . This result is comparable to literature values for  $V_2O_5 \cdot n\text{H}_2\text{O}$  and ZnO nanorod arrays [11,27]. The maximum density of emission current is 1.8 mA/cm<sup>2</sup> at a field  $\sim 18$  V/ $\mu\text{m}$ , indicative of a satisfactory FE property. A Fowler–Nordheim (F–N) plot of  $(\ln J/E^2)$  versus  $(1/E)$  appears in the inset of Fig. 5a; a linear relation indicates that the field emission from the film of  $V_2O_5$  NWs conforms to the F–N theory and the emitted current is caused by quantum tunneling at the surface [5,28]. The Raman spectrum of  $V_2O_5$  NWs as synthesized on ITO glass, at 23 °C, exhibits the vibrational pattern shown in Fig. 5b, with lines at 995, 700, 285, 147, 525, 480 and 406  $\text{cm}^{-1}$ , assigned to  $V_2O_5$  in its orthorhombic phase [12,29].

#### 4. Conclusion

We have demonstrated a deposition method simple, economical, mild and free of template to prepare vertically aligned  $V_2O_5$  NWs in the first direct synthesis of single-crystalline vanadium-oxide nanowire with an ultralarge aspect ratio. Comprehensive structural investigations including XRD, SAED, and HREM show that the NWs comprise orthorhombic  $V_2O_5$  in a pure phase growing along direction [001]. The ultraviolet and visible absorption spectrum reveals a semiconducting property with a band gap 2.48 eV, and measurements of field emission indicate a small actuation field  $\sim 8.33$  V/ $\mu\text{m}$  and a large current density. The  $V_2O_5$  NWs as deposited present a unique structure and electrical properties that might be used as a FE emitter. A possible mechanism of growth is proposed. The investigation of  $V_2O_5$  NWs on various substrates, including ITO, glass slide, and titanium foil demonstrates significant advantages for the pyrolytic deposition, a method that might be extensible to the fabrication of other metal-oxide nanostructures with appropriately chosen

precursors and synthetic parameters. This mechanism is anticipated to be applied to fabricate various metal-oxide nanocrystals on oxide substrates with special crystal morphologies on choosing a suitable precursor.

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### References

- [1] F. Zhou, X. Zhao, C.G. Yuan, L. Li, *Cryst. Growth Des.* 8 (2008) 723.
- [2] K.-C. Cheng, F.-R. Cheng, J.-J. Kai, *Sol. Energy Mater. Sol. Cell.* 90 (2006) 1156.
- [3] W. Chen, C. Zhou, L. Mai, Y. Liu, Y. Qi, Y. Dai, *J. Phys. Chem. C* 112 (2008) 2262.
- [4] K. Takahashi, S.J. Limmer, Y. Wang, G. Cao, *J. Phys. Chem. B* 108 (2004) 9795.
- [5] L. Mai, W. Guo, B. Hu, W. Jin, W. Chen, *J. Phys. Chem. C* 112 (2008) 423.
- [6] L. Kong, Z. Liu, M. Shao, Q. Xie, W. Yu, Y. Qian, *J. Solid State Chem.* 17 (2004) 690.
- [7] R. Ostermann, D. Li, Y. Yin, T. McCann, Y. Xia, *Nano Lett.* 6 (2006) 1297.
- [8] H. Zhu, Z. Zheng, X. Gao, Y. Huang, Z. Yan, J. Zou, H. Yin, Q. Zou, S.H. Kable, J. Zhao, Y. Xi, W.N. Martens, R.L. Frost, *J. Am. Chem. Soc.* 128 (2006) 2373.
- [9] M. Law, L.E. Greene, J.C. Johnson, R. Saykall, P.D. Yang, *Nature* 4 (2005) 455.
- [10] S. Nishio, *Chem. Mater.* 14 (2002) 3730.
- [11] C. Zhou, L. Mai, Y. Liu, Y. Qi, Y. Dai, W. Chen, *J. Phys. Chem. C* 111 (2007) 8202.
- [12] S.T. Oyama, G.T. Went, K.B. Lewis, A.T. Bell, G.A. Somorjai, *J. Phys. Chem. B* 93 (1999) 6786.
- [13] C.-J. Mao, H.-C. Pan, X.-C. Wu, J.-J. Zhu, H.-Y. Chen, *J. Phys. Chem. B* 110 (2006) 14709.
- [14] L. Chen, B. Yang, X. Zhang, W. Dong, K. Cao, X. Zhang, *Energy Fuels* 20 (2006) 915.
- [15] C.K. Chan, H. Peng, R.D. Twosten, K. Jarausch, X.F. Zhang, Y. Cui, *Nano Lett.* 7 (2007) 490.
- [16] V. Protasenko, S. Gordeyev, M. Kuno, *J. Am. Chem. Soc.* 129 (2007).
- [17] S. Shi, M. Cao, X. He, H. Xie, *Cryst. Growth Des.* 7 (2007) 1893.
- [18] C. Díaz-Guerra, J. Piqueras, *Cryst. Growth Des.* 8 (2008) 1031.
- [19] D. Barreca, L. Armelao, F. Caccavale, V.D. Noto, A. Gregori, G.A. Rizzi, E. Tondello, *Chem. Mater.* 12 (2000) 98.
- [20] C.V. Ramana, R.J. Smith, O.M. Hussain, C.C. Chusuei, C.M. Julien, *Chem. Mater.* 17 (2005) 1213.
- [21] J. Livage, *Chem. Mater.* 3 (1991) 578.
- [22] M.C. Wu, C.S. Lee, *Mater. Res. Bull.* 44 (2009) 629.
- [23] B. Laugier, J. Bochu, Celref, <<http://www.inpg.fr/LMGP>>; Laboratoire des Matériaux et du Génie Physique de l'Ecole Supérieure de Physique de Grenoble.
- [24] W. Yang, C. Lu, X. Zhan, H. Zhuang, *Inorg. Chem.* 41 (2002) 4621.
- [25] A. Talledo, C.G. Granqvist, *J. Appl. Phys.* 77 (1995) 4655.
- [26] J.C. Parker, D.J. Lam, Y.N. Xu, W.Y. Ching, *Phys. Rev. B* 42 (1990) 5289.
- [27] X.P. Yuan, A.H. Hu, Y.M. Jiang, Y. Xu, Z. Hu, *Nature Nanotechnol.* 16 (2005) 2039.
- [28] Q. Tang, T. Li, X.H. Chen, D.P. Yu, Y.T. Qian, *Solid State Commun.* 134 (2005) 229.
- [29] J. Wang, K.E. Gonsalves, *J. Comb. Chem.* 1 (1999) 216.